

(19) United States

(12) Patent Application Publication (10) Pub. No.: US 2023/0231363 A1 TONG et al.

Jul. 20, 2023 (43) **Pub. Date:**

(54) SURFACE-EMITTING SEMICONDUCTOR LASER BASED ON A TRIPLE-LATTICE PHOTONIC CRYSTAL STRUCTURE

(71) Applicant: Changchun Institute of Optics, Fine Mechanics and Physics, Chinese

Academy of Sciences, Changchun (CN)

(72) Inventors: Cunzhu TONG, Changchun (CN); Ziye

WANG, Changchun (CN); Pinyao WANG, Changchun (CN); Huanyu LU, Changchun (CN); Lijun WANG,

Changehun (CN)

(21) Appl. No.: 18/179,048

(22) Filed: Mar. 6, 2023

Foreign Application Priority Data (30)

Jun. 20, 2022 (CN) 202210696112.X

Publication Classification

(51) Int. Cl. H01S 5/11 (2006.01)H01S 5/343 (2006.01)H01S 5/18 (2006.01)

U.S. Cl. H01S 5/11 (2021.01); H01S 5/34313 CPC (2013.01); H01S 5/18 (2013.01)

(57)ABSTRACT

A surface-emitting semiconductor laser based on a triplelattice photonic crystal structure, including: a P-type electrode, a P-type contact layer, a P-type cladding layer, a photonic crystal layer, an active layer, an N-type cladding layer, an N-type contact layer, an N-type substrate, and an N-type electrode successively arranged from top to bottom. The photonic crystal layer has a triple-lattice photonic crystal structure, which is formed by a plurality of square unit cells arranged periodically. Each square unit cell includes three identical air holes, namely, a first air hole, a second air hole, and a third air hole. A distance between a center of the first air hole and a center of the second air hole is (0.5±0.1) a, and a distance between a center of the third air hole and the center of the second air hole is (0.5 ± 0.1) a, where a is the lattice constant.

